

REMARKS

Applicants request favorable consideration and allowance of the subject application in view of the preceding amendments and the following remarks.


The specification has been amended to reference the continuing status of this application, and to place the application in better form. No new matter has been added.

Claim 14 is presented for consideration. Claims 1-13 and 15-18 have been canceled without prejudice or disclaimer.

Applicants submit that independent claim 14 patentably defines features of the method for manufacturing a substrate having a fine line of the present invention. Applicants submit, therefore, that this application is in condition for allowance. Favorable consideration and an early passage to issue are requested.

Applicants' undersigned attorney may be reached in our Washington, D.C. office by telephone at (202) 530-1010. All correspondence should be directed to our address listed below.

Respectfully submitted,



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